

PATENT APPLICATION
Docket No. 9898-321
Client No. SS-18146-US

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

					. •	•
l'n	ro	an	nl	103	tion	ot.
111	10	aυ	\mathbf{v}_{1}	1 Ca	LIVII	UI.

Ki-Yeon Park, et al.

Conf. No.

8248

Serial No.

10/713,577

Examiner:

Not yet assigned

Filed:

November 12, 2003

Art Unit:

2818

For:

CAPACITOR OF SEMICONDUCTOR MEMORY DEVICE THAT HAS COMPOSITE AI2O3/HfO2 DIELECTRIC LAYER AND METHOD OF MANUFACTURING THE

SAME

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

INFORMATION DISCLOSURE STATEMENT

Sir:	
This Inf	Formation Disclosure Statement is submitted:
\boxtimes	under 37 CFR 1.97 (b); or
or h	(Within three months of filing national application; or date of entry of International application; pefore mailing date of first office action on the merits; whichever occurs last)
	under 37 CFR 1.97 (c) together with either a:
	Statement under 37 CFR 1.97 (e), or
	a \$180 fee under 37 CFR 1.17 (p); or
_	(After mailing of first Office Action, but prior to Notice of Allowance or Final Office Action)
	under 37 CFR 1.97 (d) together with:
	Statement under 37 CFR 1.97 (e), and
	a \$180.00 fee set forth in 37 CFR 1.17 (p).
	(Filed after final action or notice of allowance, whichever occurs first, but before payment of
the issue fee)	
	Applicant(s) submit herewith Form PTO 1449- Information Disclosure Citation together with
	, publications or other information of which applicant(s) are aware, which applicant(s) believe(s) to the examination of this application and for which there may be a duty to disclose in accordance
with 37 CFR 1.5	••
It is req	uested that the information disclosed herein be made of record in this application.

Customer No. 20575

Respectfully submitted,

Any deficiency or overpayment should be charged or credited to deposit account number 13-1703. A

MARGER JOHNSON & McCOLLOM, P.C.

Alan T. McCollom Reg. No. 28,881

MARGER JOHNSON & McCOLLOM, P.C. 1030 SW Morrison Street Portland, OR 97205 503-222-3613

duplicate copy of this sheet is enclosed.

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450

Date: July 9, 2004

Angie C. Farr



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:	Ki-Yeon Park, et al.	Conf. No.	8248

Serial No. 10/713,577 Examiner: Not yet assigned

Filed: November 12, 2003 Art Unit: 2818

For: CAPACITOR OF SEMICONDUCTOR MEMORY DEVICE

THAT HAS COMPOSITE AI203/Hf02 DIELECTRIC LAYER AND METHOD OF MANUFACTURING THE

SAME

INFORMATION DISCLOSURE CITATION FORM PTO-1449 (Modified)

FOREIGN PATENT DOCUMENTS

Exam <u>Init</u>	Ref	Publication <u>Number</u>	Publication <u>Date</u>	<u>Country</u>	<u>Name</u>			
		P2002-0002596	Jan. 10, 2002	Korea				
		P2002-0034520	May 9, 2002	Korea				
		9	OTHER DOCUM	<u>IENTS</u>				
Exam <u>Init</u>	Ref	Ref Author, Title, Date, Pertinent Pages, Etc.)						
<u> </u>		English Language Abstract of Korean Publication No: P2002-0002596						
		English Language A	Abstract of Korean	Publication No: P200	2-0034520			
Examiner: _								
Date Consid	dered:							